

PROCESS CPS057

Silicon Controlled Rectifier

查询"CPS057"供应商

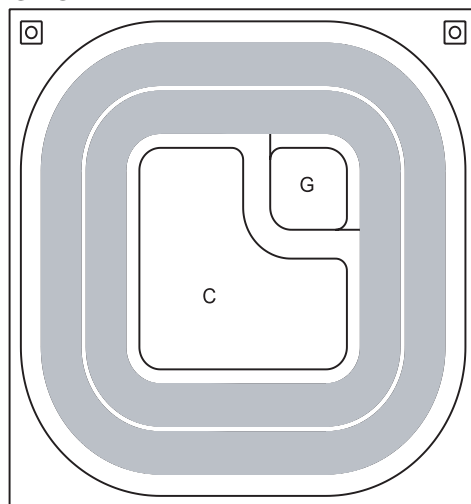
Sensitive Gate SCR Chip

CentralTM
Semiconductor Corp.

PROCESS DETAILS

Process	GLASS PASSIVATED MESA
Die Size	57 x 57 MILS
Die Thickness	8.7 MILS $\pm$ 0.6 MILS
Cathode Bonding Pad Area	24 x 14 MILS
Gate Bonding Pad Area	7.9 x 7.9 MILS
Top Side Metalization	Al - 45,000Å
Back Side Metalization	Al/Mo/Ni/Ag - 32,000Å

GEOMETRY



BACKSIDE ANODE

R0

GROSS DIE PER 4 INCH WAFER

3,374

PRINCIPAL DEVICE TYPES

CS39-4D

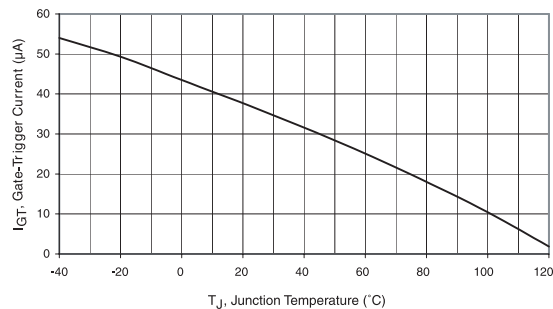
2N2323 thru 2N2329

CS223-4M

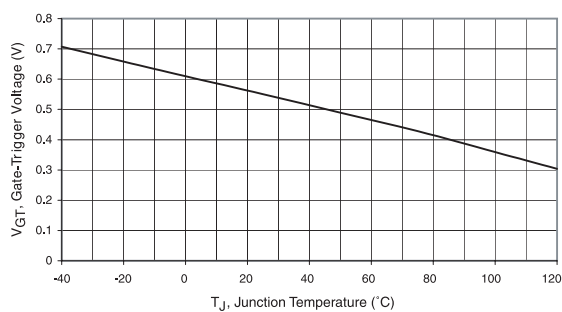
145 Adams Avenue
Hauppauge, NY 11788 USA
Tel: (631) 435-1110
Fax: (631) 435-1824
www.centalsemi.com

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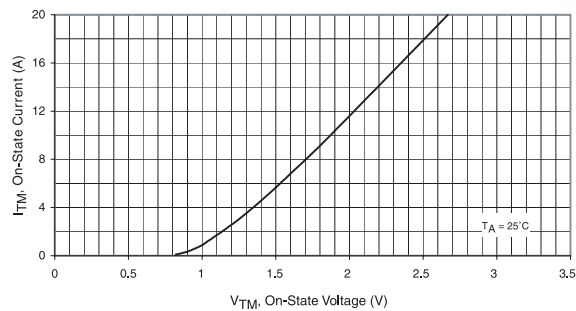
Typical Gate-Trigger Current



Typical Gate-Trigger Voltage



Typical On-State Voltage



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